

Mn

MANGANESE SPUTTERING TARGET

Manganese sputtering target is composed of high purity manganese metal. Manganese is a chemical element with symbol Mn and atomic number 25. It is not found as a free element in nature; it is often found in minerals in combination with iron. Manganese is a metal with important industrial metal alloy uses, particularly in stainless steels.

Quick Facts

Product	: Manganese Sputtering Target
Stock No	: NS6130-10-1041
CAS	: 7439-96-5

Application

- ✓ Electronics
- ✓ Semiconductor
- ✓ Flat panel displays

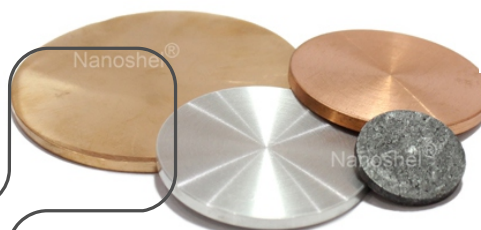
Additional Characteristics

Purity	Type of Bond	Diameter	Thickness
99.99%	Elastomer	50.8 mm ± 1mm	3 mm ± 0.5mm

Technical Specification

Molecular Formula	Type of Bond	Thermal Conductivity
Mn	54.98 g/mol	7.8 W/cm/K @ 298.2 K

High Purity
SPUTTERING
TARGET



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| www.nanoshel.com | sales@nanoshel.com

INTELLIGENT MATERIALS PVT LTD

Derabassi
Punjab (140507)
INDIA

+91 9779 550077, 9779238252

NANOSHEL UK LIMITED

Chapel House,
Chapel St Cheshire,
CW12 4AB United Kingdom

+44 (0) 74 105 488, +44 203 137 5187

NANOSHEL LLC

3422 Old Capitol Suit
1305 Wilmington DE - 19808
United States

+1 646 470 4911

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CERTIFIED COMPANY



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